CHEMFIRST INC Form DEFA14A July 25, 2002

SCHEDULE 14A

(Rule 14a-101)

INFORMATION REQUIRED IN PROXY STATEMENT

SCHEDULE 14A INFORMATION

Proxy Statement Pursuant to Section 14(a) of the Securities Exchange Act of 1934 (Amendment No.)

	Enonange nee of 1991 (finenan	iene no. ,	
File	ed by the Registrant [x]		
File	ed by a Party other than the Registrant []		
Chec	k the appropriate box:		
[]	Preliminary Proxy Statement	[] Confidential, For Use of the Commission Only (as	
[x]	Definitive Proxy Statement Definitive Additional Materials Soliciting Material Under Rule 14a-12	permitted by Rule 14a-6(e)(2)	
	ChemFirst Inc.		
	(Name of Registrant as Specified	in Its Charter)	
(N	ame of Person(s) Filing Proxy Statement, if	Other Than the Registrant)	
_	ment of Filing Fee (Check the appropriate bo No fee required.	x):	
[]	Fee computed on table below per Exchange A $0-11$.	ct Rules 14a-6(i)(1) and	
	(1) Title of each class of securities to w	hich transaction applies:	
	(2) Aggregate number of securities to whic	h transaction applies:	
	(3) Per unit price or other underlying val pursuant to Exchange Act Rule 0-11 (Set fo filing fee is calculated and state how it	rth amount on which the	
	(4) Proposed maximum aggregate value of tr	ansaction:	
	(5) Total fee paid:		
[]	Fee paid previously with preliminary materi	als:	
[]	Check box if any part of the fee is offset	as provided by Exchange Act	

Rule 0-11(a)(2) and identify the filing for which the offsetting fee was paid previously. Identify the previous filing by registration statement number, or the Form or Schedule and the date of its filing.

(1)	Amount Previously Paid:
(2)	Form, Schedule or Registration Statement No.:
(3)	Filing Party:
(4)	Date Filed:

In connection with the transaction discussed in the following slides, ChemFirst Inc. intends to file a proxy statement with the Securities and Exchange Commission. Security holders are urged to read the proxy statement when it becomes available because it will contain important information. Security holders may obtain a free copy of the proxy statement when it becomes available, as well as other materials filed with the Securities and Exchange Commission concerning ChemFirst, at the Securities and Exchange Commission's web site at http://www.sec.gov. Security holders of ChemFirst Inc. may also obtain for free the proxy statement filed by ChemFirst Inc. with the Securities and Exchange Commission in connection with the transaction by directing a request to ChemFirst Inc., Attention: Investor Relations Department, P.O. Box 1249, Jackson, MS 39215-1249, (601) 949-0213.

ChemFirst Inc. and its directors and executive officers may be deemed to be participants in the solicitation of proxies from ChemFirst shareholders with respect to the transaction. Information regarding these directors and executive officers and their ownership of ChemFirst common stock is contained in ChemFirst Inc.'s proxy statement on Schedule 14A, filed with the Securities and Exchange Commission on March 25, 2002, in connection with the 2002 annual meeting ChemFirst shareholders. Investors may obtain additional information regarding the interests of such participants by reading the proxy statement regarding the transaction when it becomes available.

1

ChemFirst Overview

ChemFirst is a leading producer of electronic and other specialty chemicals and is a major producer of polyurethane chemicals with 2001 sales of \$278MM\$ and 486 employees.

	ChemFirst Electronic	EKC Technologies	First Chemical
	Materials (formerly Triquest)		Corporation
Products	Semiconductor	Stippers &	Aniline
	photoresist	Removers	Nitrotoluenes &
	polymers	CMP	Derivatives

Principal Segments	Photoresists		Electronic materials for semiconductors, flat panel displays, MPU and DRAM	MDI (foams, fillers, sealants)
2001 Revenues		\$86M		\$192M
2001 EBITDA		\$7M		\$43M

2

STRATEGIC FIT:

Provides a high growth Electronic Technologies opportunity while Aniline adds immediate earnings.

	Electronic Technologies Strategic Fit		Aniline Strategic Fit
0	Create stronger base in high growth semiconductor chip fabrication business.	0	Aniline adds attractive earnings from day one. Complements high future growth from electronic
0	Become a leader in current generation of advanced		technologies.
	<pre>photoresist polymers - enhance DuPont's next generation capabilities.</pre>	0	MDI is growing at 2X GDP driven by polyurethane replacing wood and metal in construction.
0	Provide greater CMP scale. Protentially complements current DuPont-Air Products Nanomaterials JV.	0	Acquisition provides step-change growth & diversifies customer base.
0	Provides a leading position in strippers & removers, as well as market access for DuPont technologies.	0	DuPont has the functional capabilities to deliver technology, operations, and supply chain synergies.

3

ChemFirst Electronic Technologies - Segments Served

ChemFirst Elec. Materials

Develops and markets 248nm

[GRAPHIC OMITTED]

photoresist polymers for semiconductor manufacturing.

Segment Size

		2001	CAGR
IC	Photoresists - Standard - Advanced	\$0.7B \$0.1B	8% 13%

EKC Technologies

Removers/Strippers -- Develops and markets photoresist and etch residue removers for semiconductor manufacturing.

	Segment Size	
	2001	CAGR
Strippers/Removers	\$0.3B	14%

CMP -- Develops and markets Chemical Mechanical Planarization slurries for semiconductor manufacturing.

			Segment	Size	
			2001	CA	AGR
Chem	Mech	Planar.	\$0.31	В 20)응+

4

ChemFirst Electronic Materials Businesses (Strong IC Fabrication Materials Position)

- Commercial technology to enable smaller linewidth semi-conductor devices

o Growth Drivers

- Enhance DuPont's 157nm photoresist technology
- o Position
- Position o Position o Position A leader in US, Position Position in 248nm DUV photoresist polymers

- o Growth Drivers o Growth Drivers
 Increased number of Shrinking linewidths
 metal interconnect Increased number of
 metal layers layers

 - Expand DuPont Tech
 - - Europe and Pac Rim

EKC CMP

- - metal layers
- Silicon wafer growth Relationship with DANM JV
 - - Positioned for strong growth with STI, tungsten, and copper slurries

5